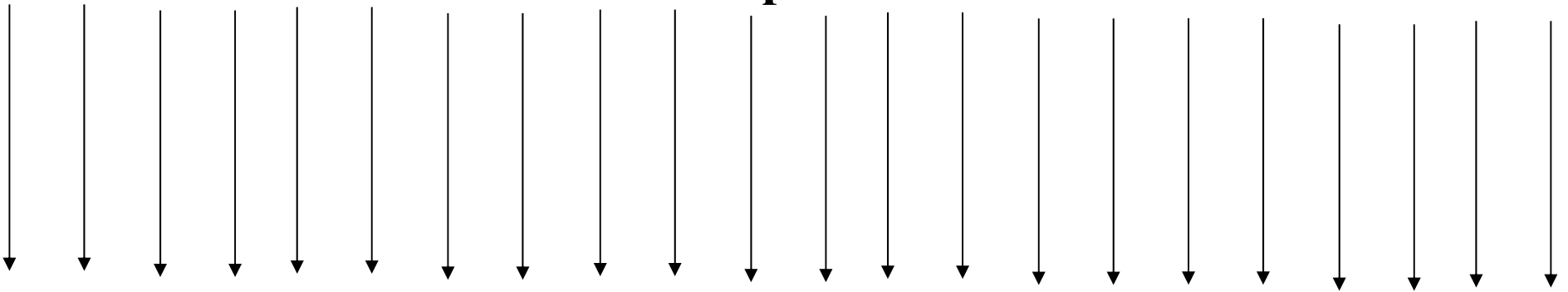


14. Optoelectronics

Jan. 23, 2019

Implant



SiO₂

Deposit oxide

Spin resist

Expose

Develop

Etch Oxide

Strip resist

Implant subcollector n+

p-Si

Antimony (Sb) has a low vapor pressure and won't evaporate during the subsequent CVD step

Epi-growth

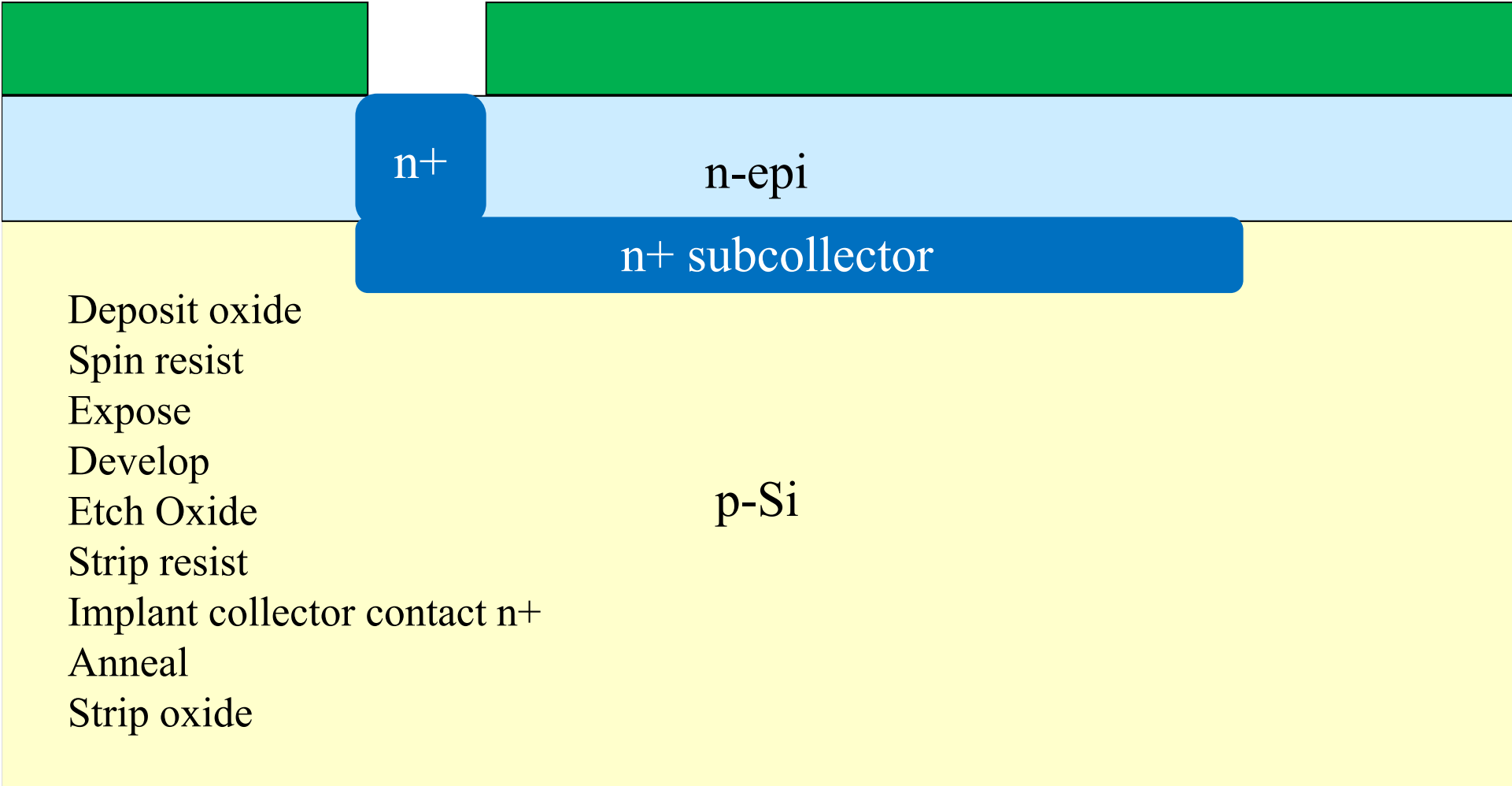
n-epi

n+ subcollector

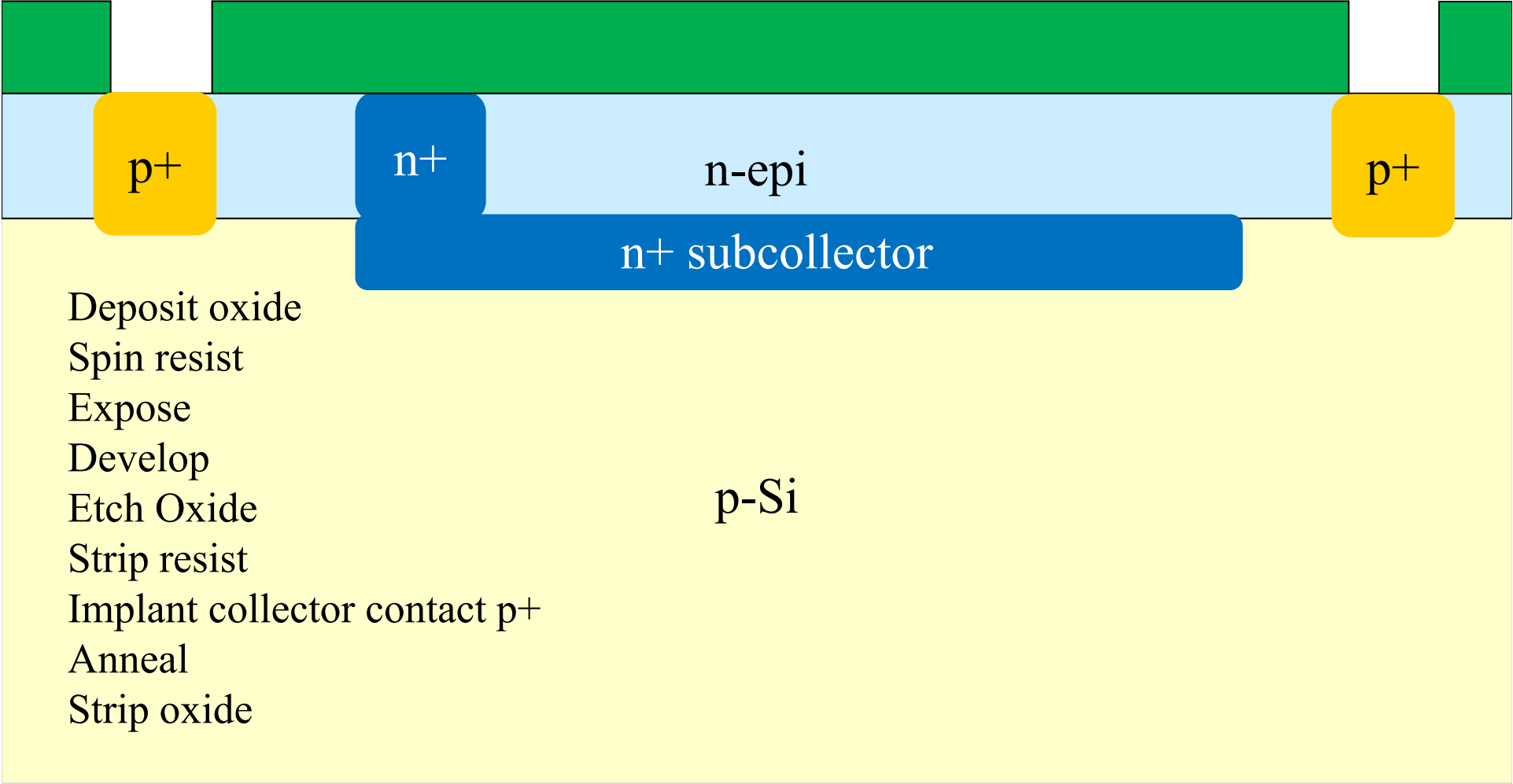
Remove oxide
Clean surface
Silicon epitaxy
CVD $\text{SiH}_4 + \text{PH}_3$

p-Si

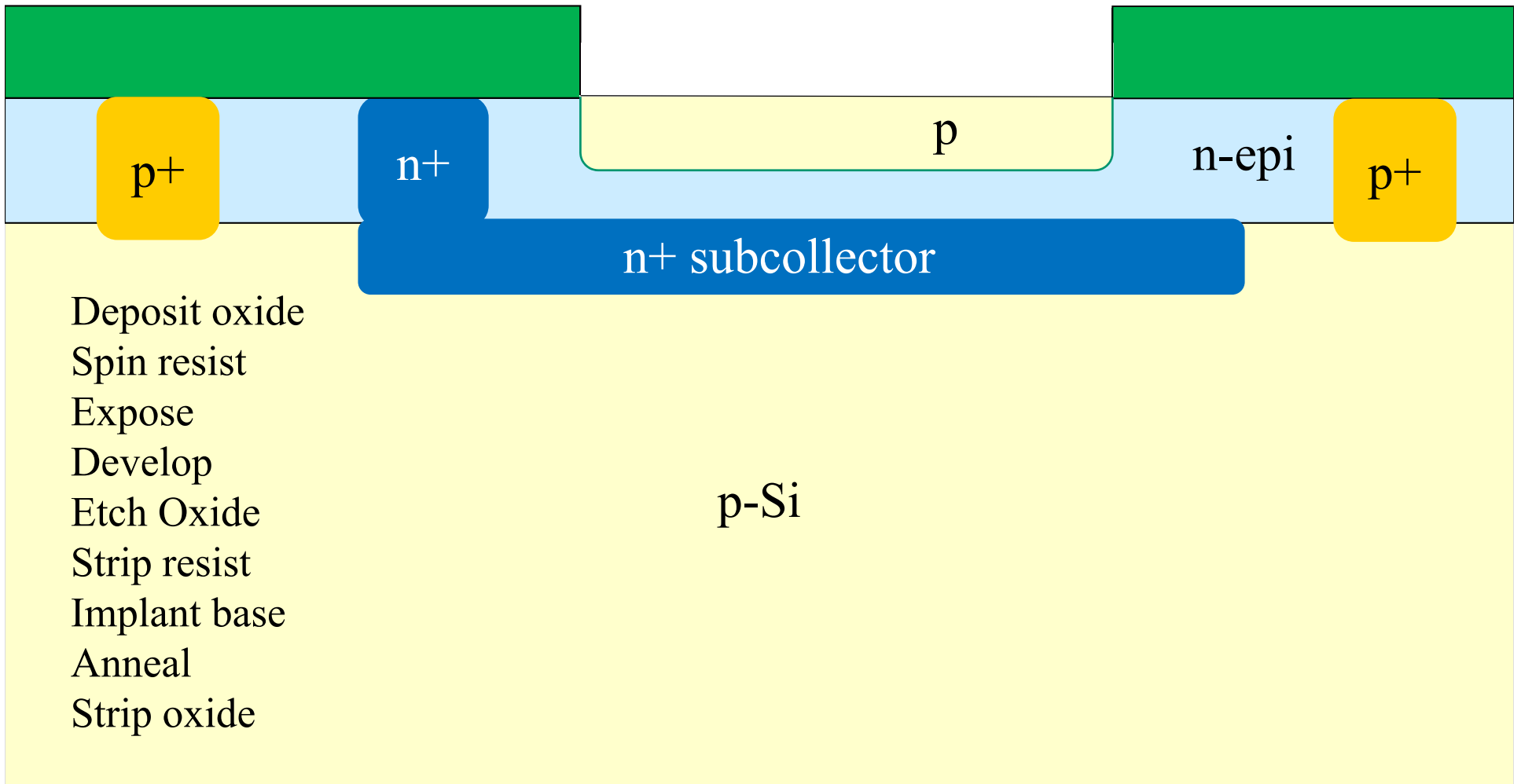
Collector Contact



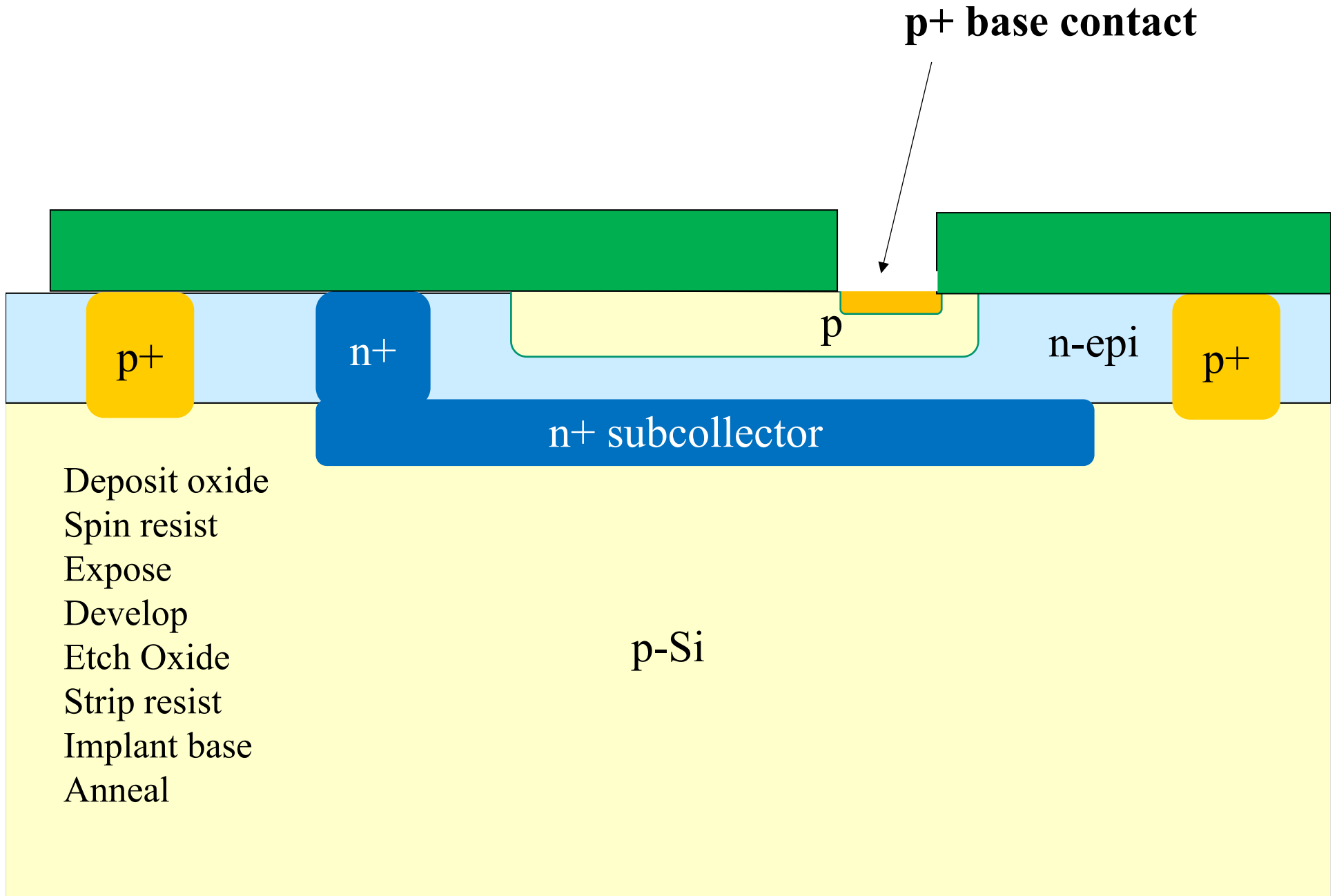
Guard ring



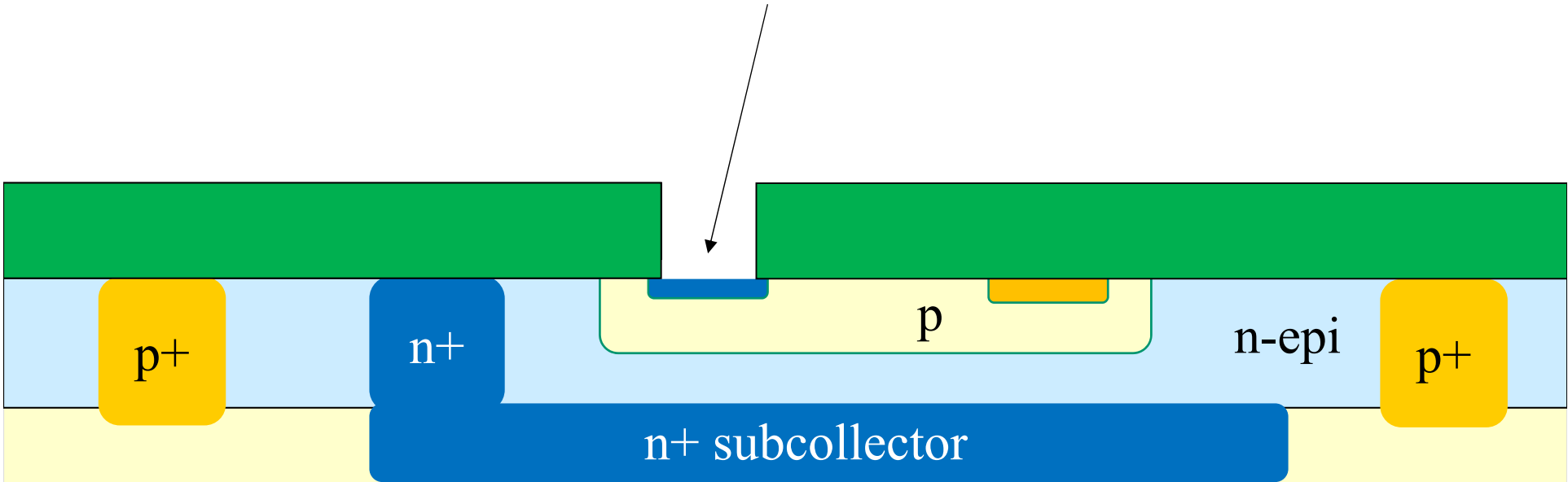
p-well



- Deposit oxide
- Spin resist
- Expose
- Develop
- Etch Oxide
- Strip resist
- Implant base
- Anneal
- Strip oxide



n+ emitter



n+ subcollector

- Deposit oxide
- Spin resist
- Expose
- Develop
- Etch Oxide
- Strip resist
- Implant base
- Anneal

p-Si

Optoelectronics

light emitting diode
laser diode
solar cell
photo detectors



communications, memory (DVD), displays, printing, bar-code readers, solar energy, lighting, laser surgery, measurement, guidance, spectroscopy, LiFi

Photo detectors

Intrinsic semiconductor $\sigma = e(\mu_n n + \mu_p p)$ (used in copiers)

Unbiased pn junction - like a solar cell

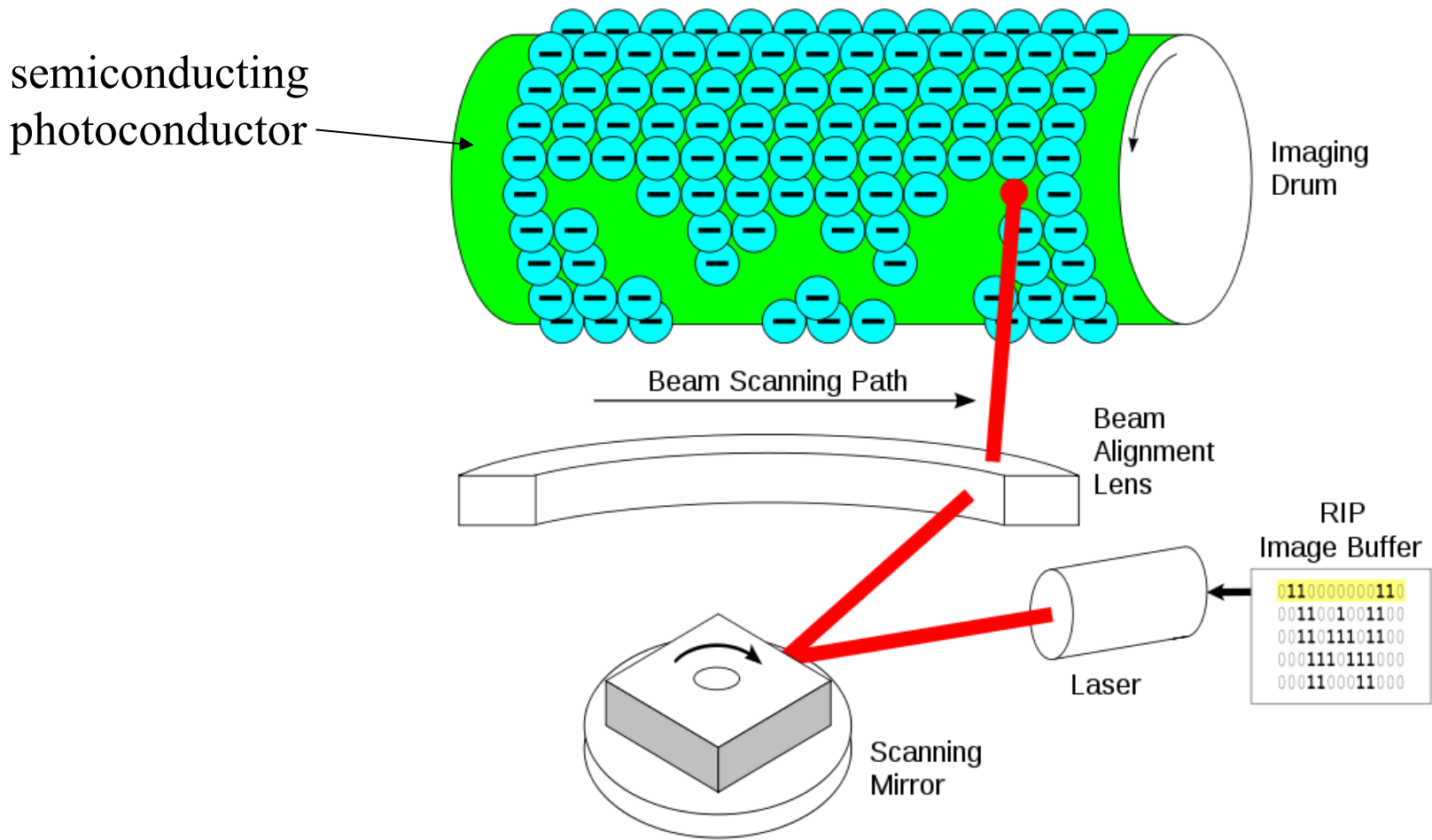
Reverse biased pn junction - smaller capacitance, higher speed, less noise

Phototransistor - light injects carriers into the base. This forward biases the emitter base junction. High responsivity.

Ambient light detectors.

Active Pixel sensors for automated parking and gesture control (uses time-of-flight to image in 3-D).

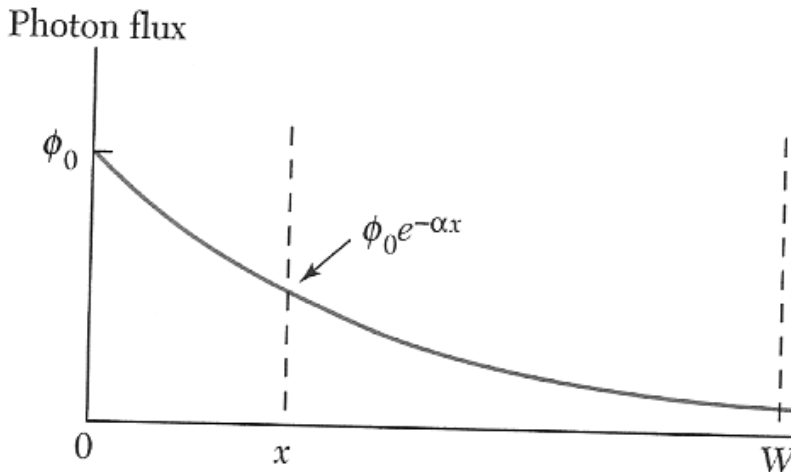
Laser printer



https://en.wikipedia.org/wiki/Laser_printing

Absorption

Photon flux: $\Phi(x) = \Phi_0 e^{-\alpha x}$

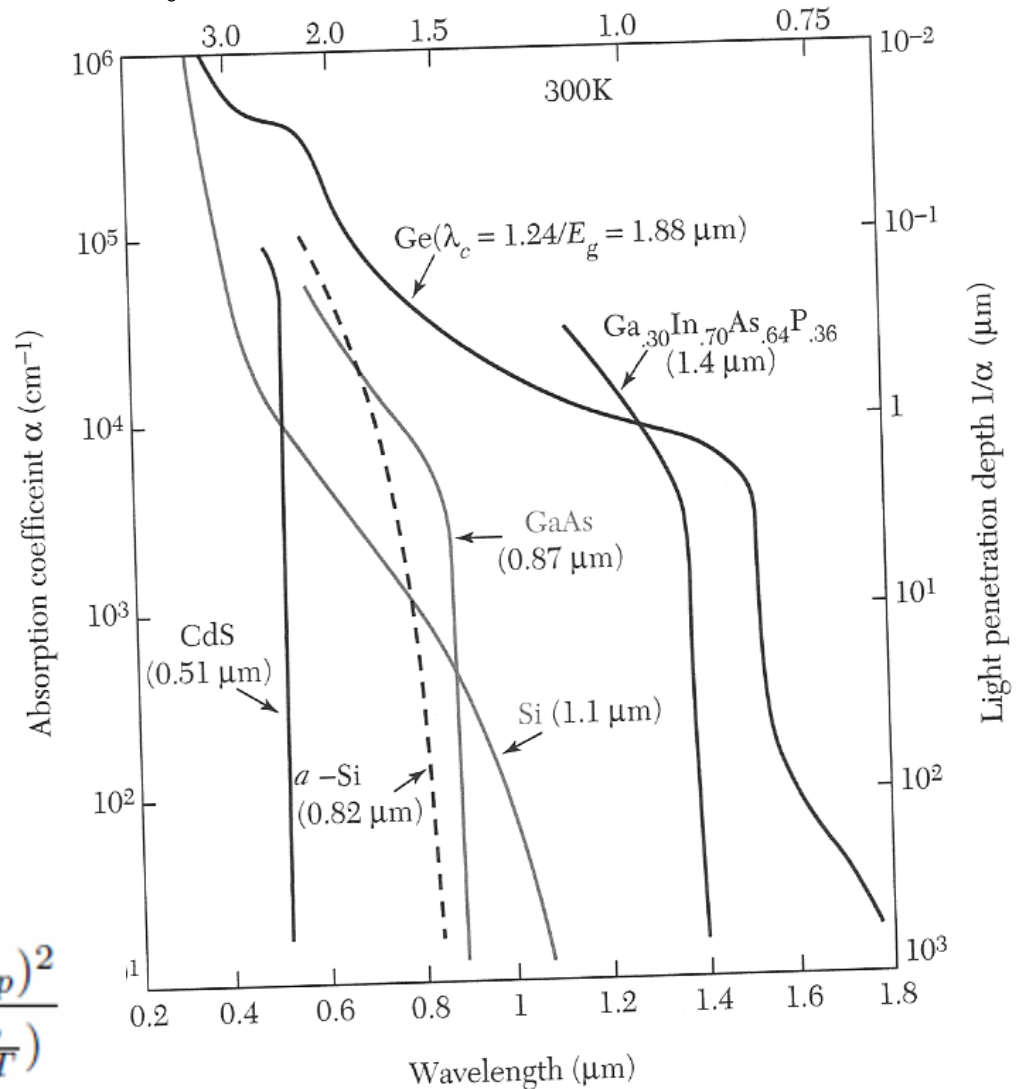


Sharp absorption edge for direct bandgap materials

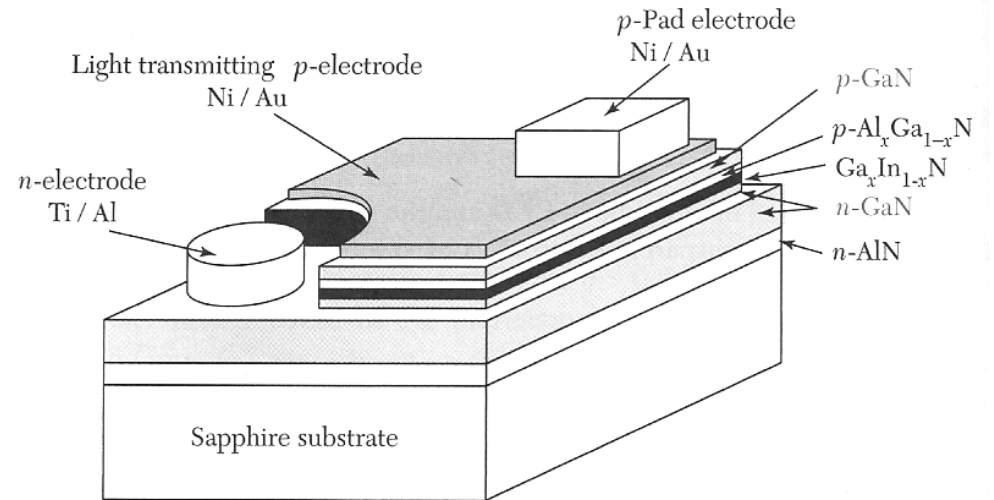
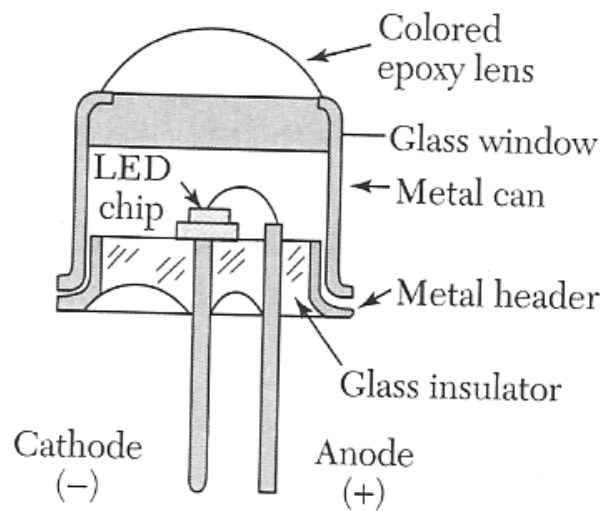
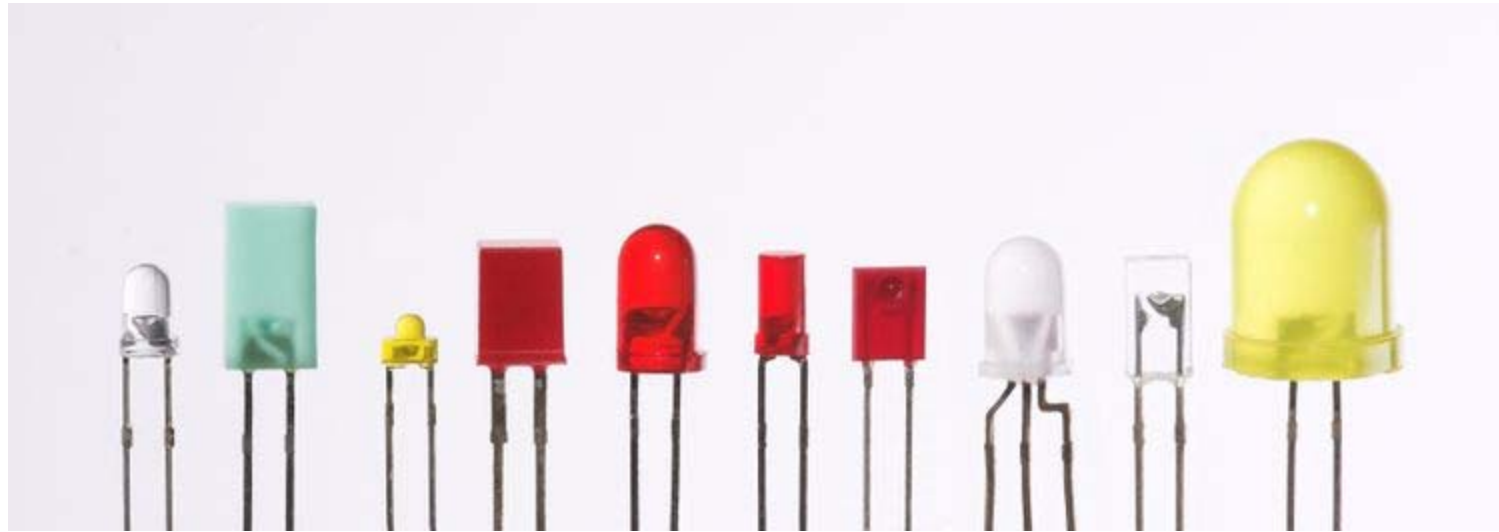
$$\alpha \approx 3.5 \times 10^6 \left(\frac{m_r^*}{m_0} \right)^{3/2} \frac{\sqrt{\hbar\omega - E_g}}{\hbar\omega} \text{ cm}^{-1}$$

direct bandgap indirect bandgap

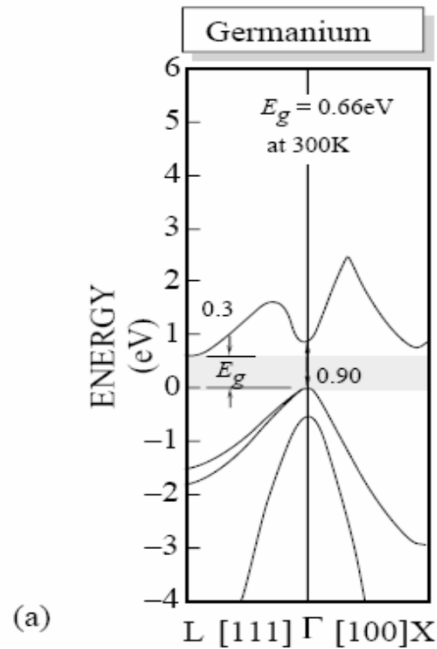
$$\alpha \propto \frac{(h\nu - E_g + E_p)^2}{\exp\left(\frac{E_p}{k_B T}\right) - 1} + \frac{(h\nu - E_g - E_p)^2}{1 - \exp\left(-\frac{E_p}{k_B T}\right)}$$



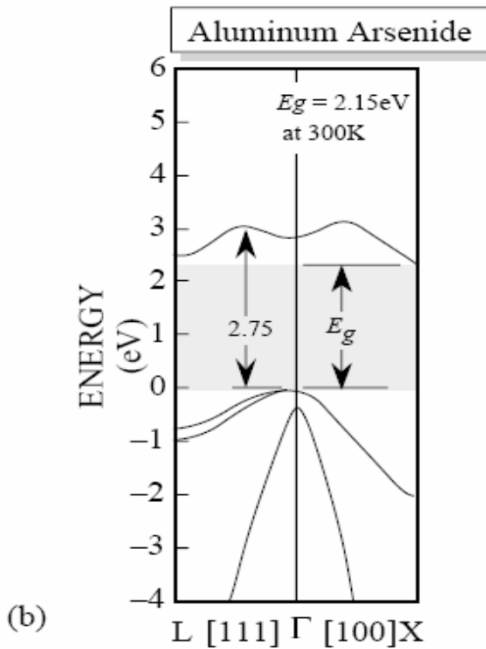
Light emitting diodes



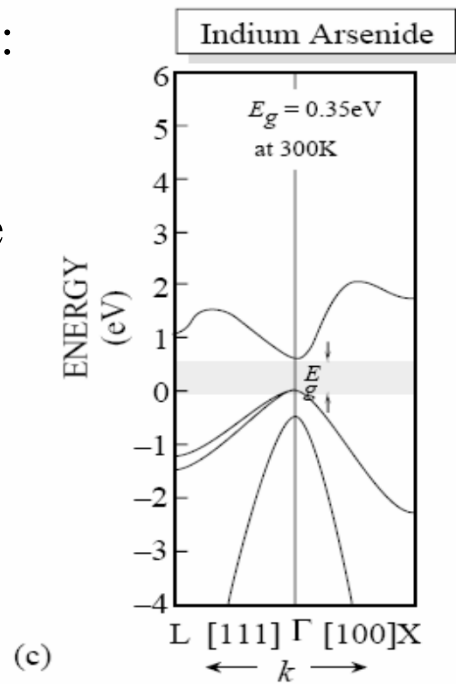
Solid state lighting is efficient.



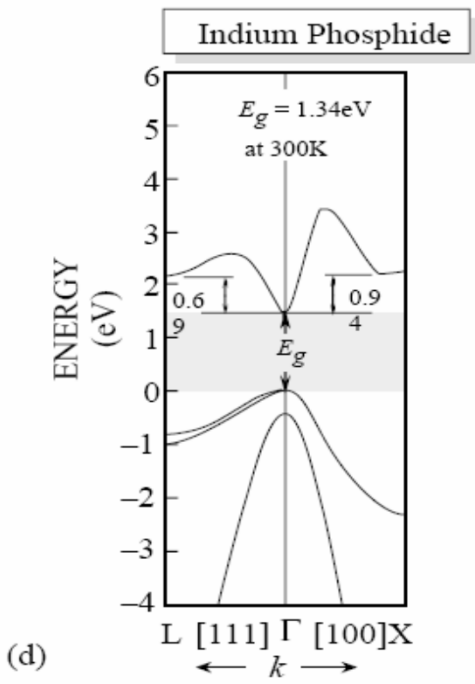
(a)



(b)



(c)



(d)

direct bandgap:
 $\Delta k = 0$

photons can be
emitted

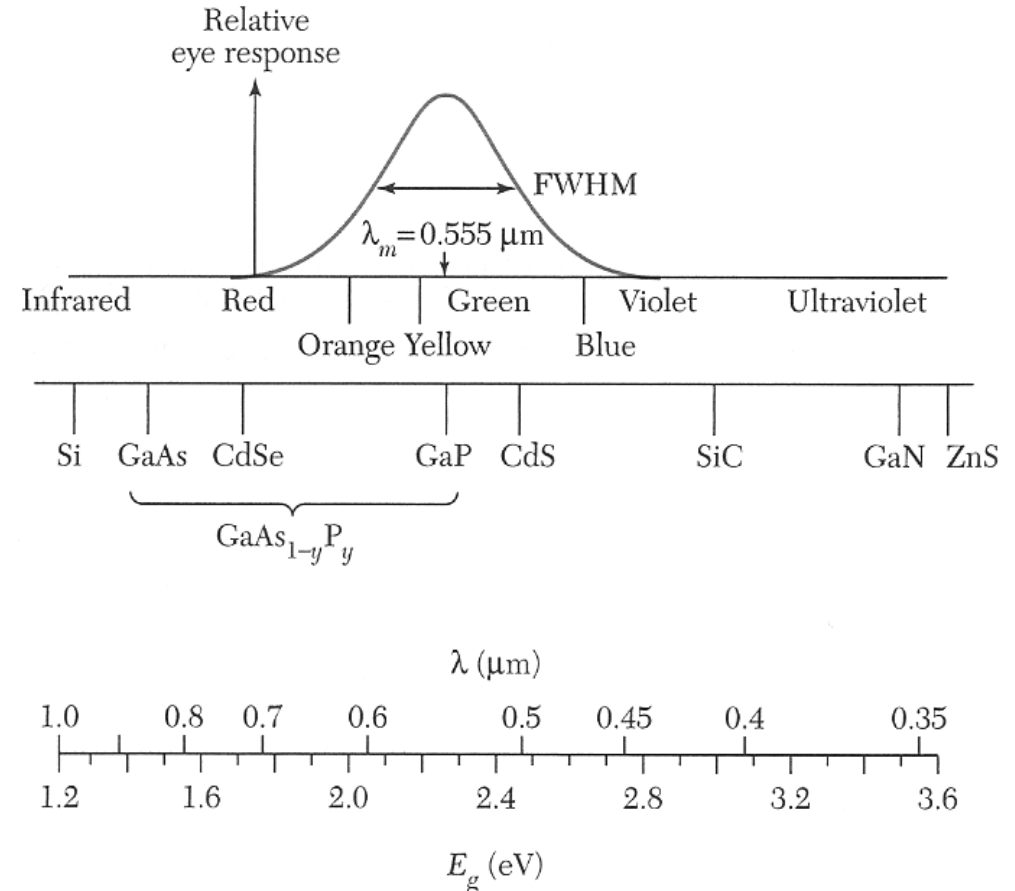
indirect bandgap:
 $\Delta k \neq 0$

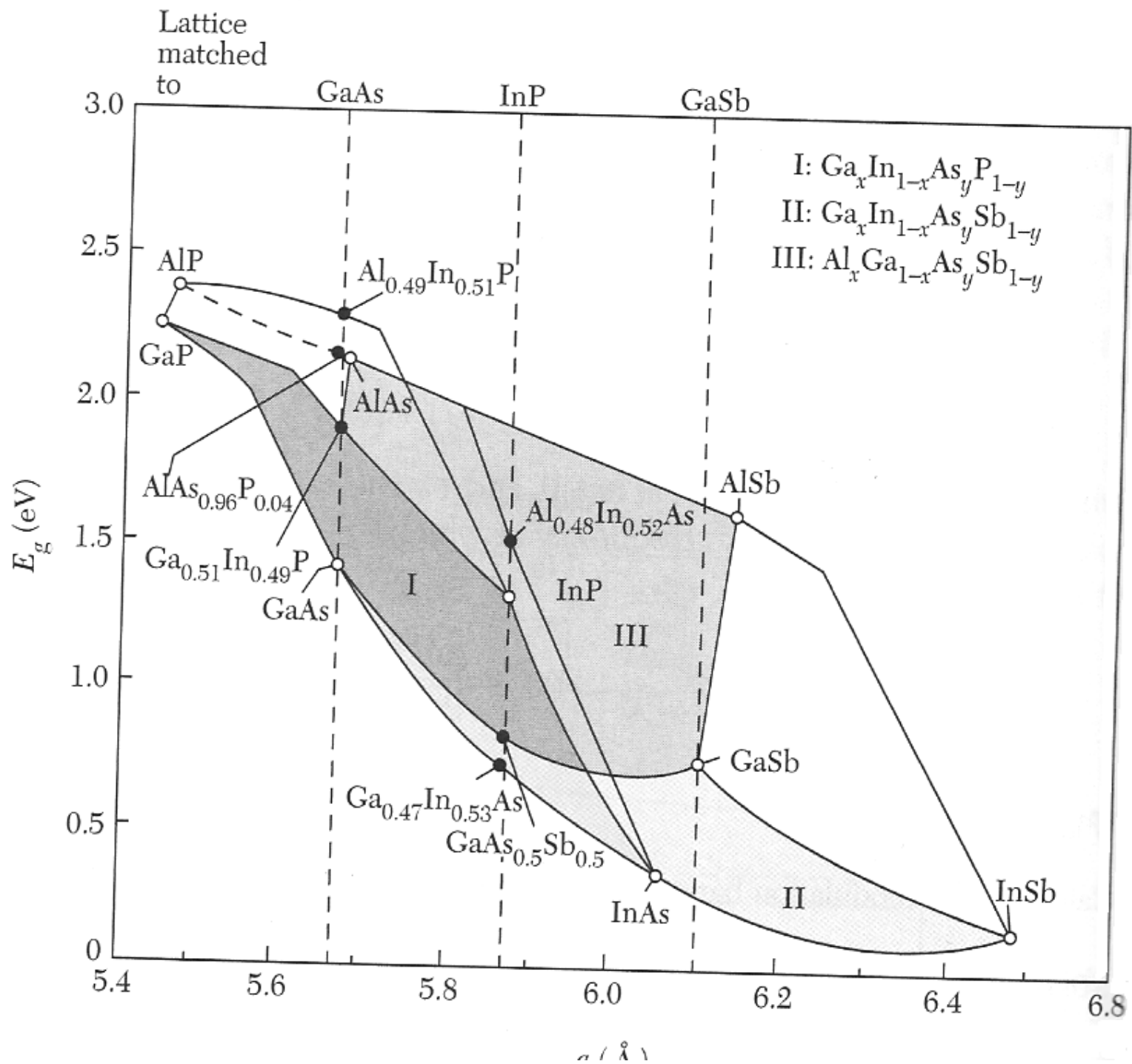
phonons are
emitted

TABLE 1 Common III-V materials used to produce LEDs and their emission wavelengths.

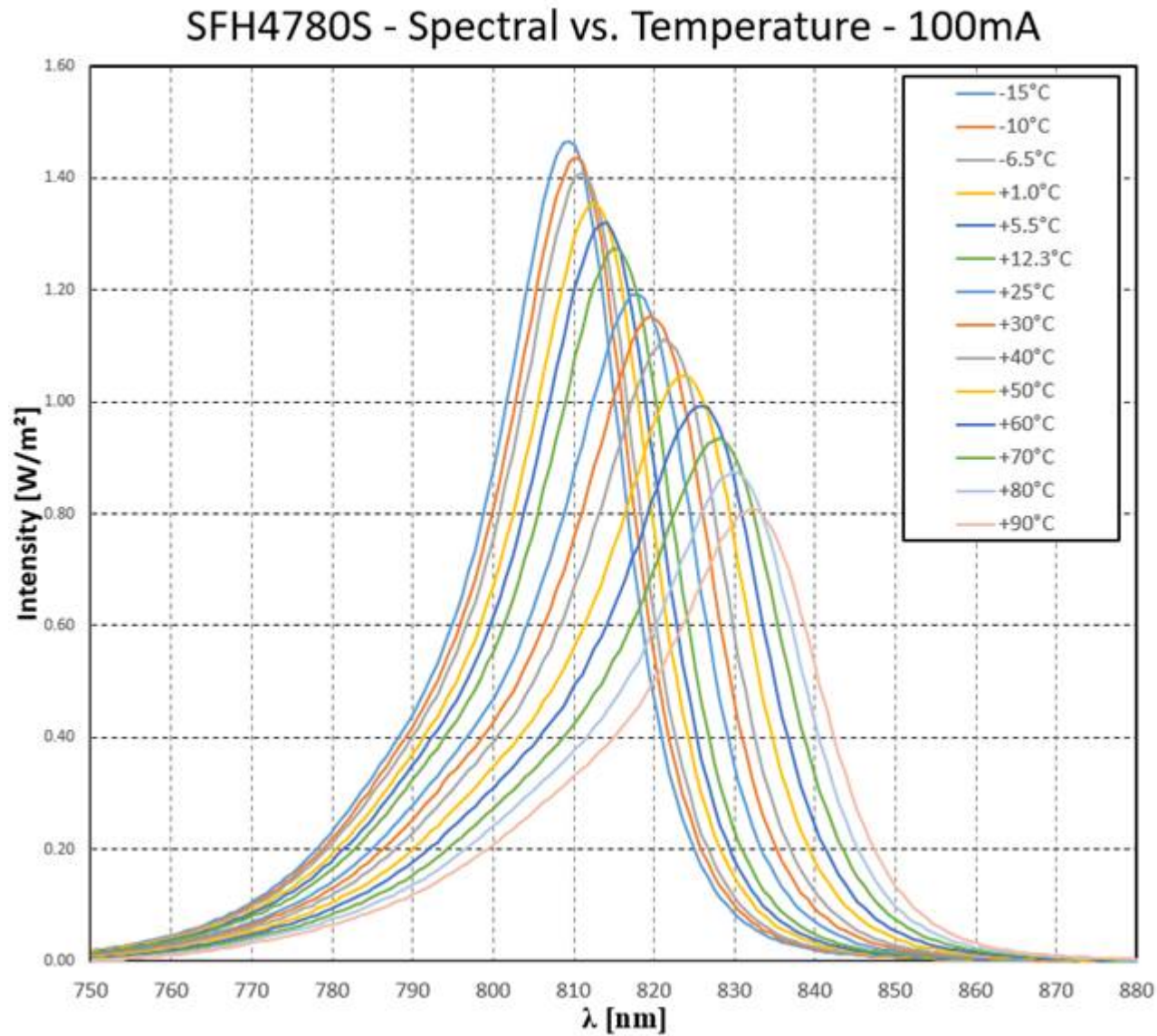
| Material | Wavelength (nm) |
|---------------------------------------|-----------------|
| InAsSbP/InAs | 4200 |
| InAs | 3800 |
| GaInAsP/GaSb | 2000 |
| GaSb | 1800 |
| $Ga_xIn_{1-x}As_{1-y}P_y$ | 1100-1600 |
| $Ga_{0.47}In_{0.53}As$ | 1550 |
| $Ga_{0.27}In_{0.73}As_{0.63}P_{0.37}$ | 1300 |
| GaAs:Er, InP:Er | 1540 |
| Si:C | 1300 |
| GaAs:Yb, InP:Yb | 1000 |
| $Al_xGa_{1-x}As:Si$ | 650-940 |
| GaAs:Si | 940 |
| $Al_{0.11}Ga_{0.89}As:Si$ | 830 |
| $Al_{0.4}Ga_{0.6}As:Si$ | 650 |
| $GaAs_{0.6}P_{0.4}$ | 660 |
| $GaAs_{0.4}P_{0.6}$ | 620 |
| $GaAs_{0.15}P_{0.85}$ | 590 |
| $(Al_xGa_{1-x})_{0.5}In_{0.5}P$ | 655 |
| GaP | 690 |
| GaP:N | 550-570 |
| $Ga_xIn_{1-x}N$ | 340,430,590 |
| SiC | 400-460 |
| BN | 260,310,490 |

Light emitting diodes



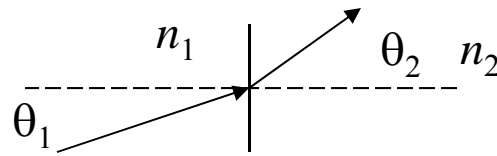
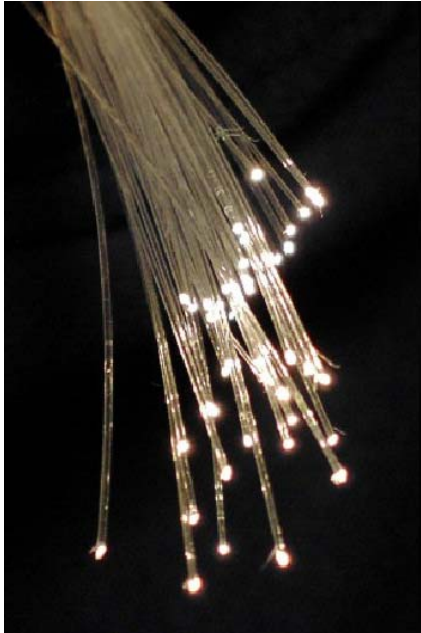


IR LED

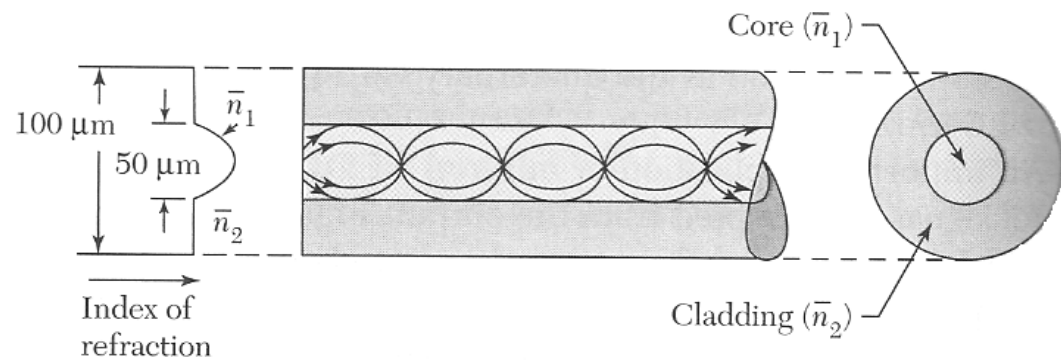
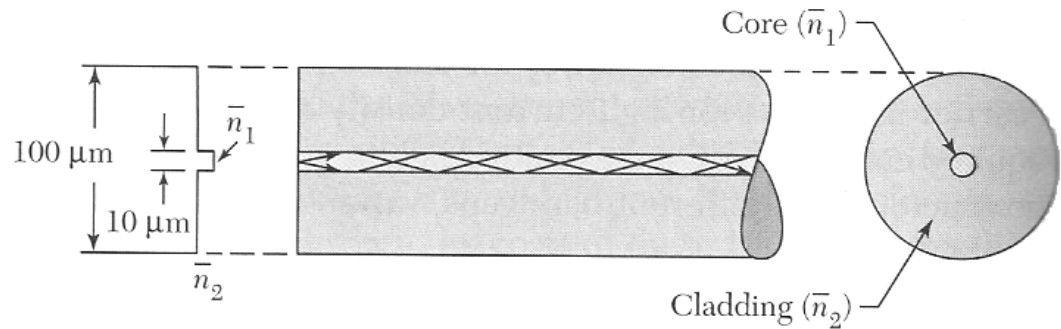


Measurement by Jan Enenkel

Confinement of light by total internal reflection



$$n_1 \sin \theta_1 = n_2 \sin \theta_2$$

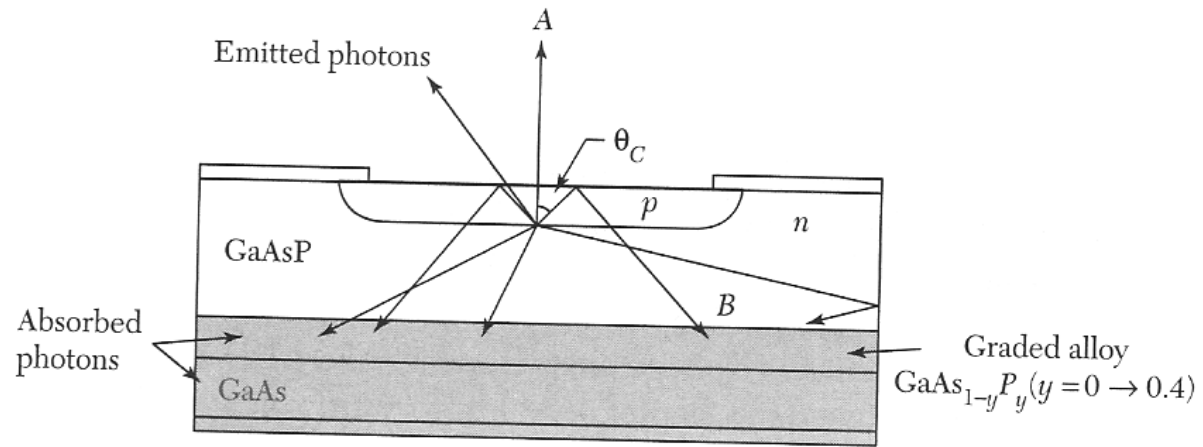


less pulse spreading for parabolically graded fiber

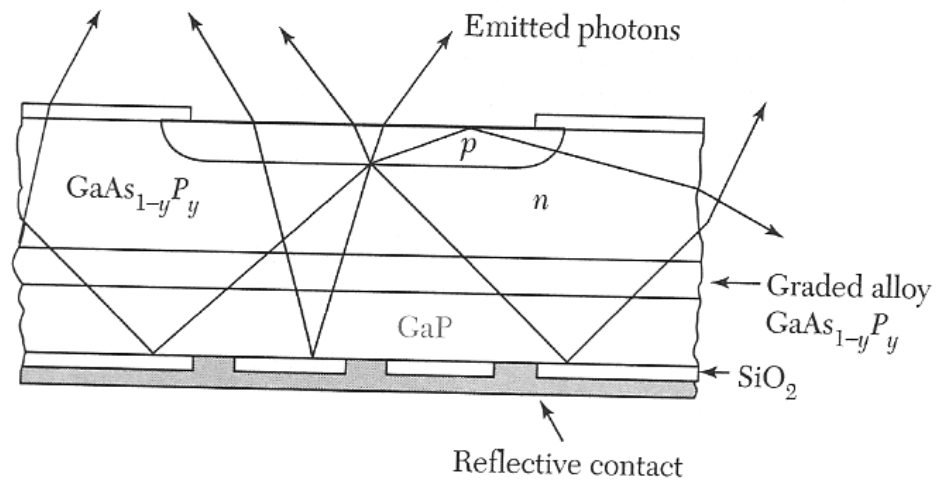


0.6 dB/km at 1.3 μm and 0.2 dB/km at 1.55 μm

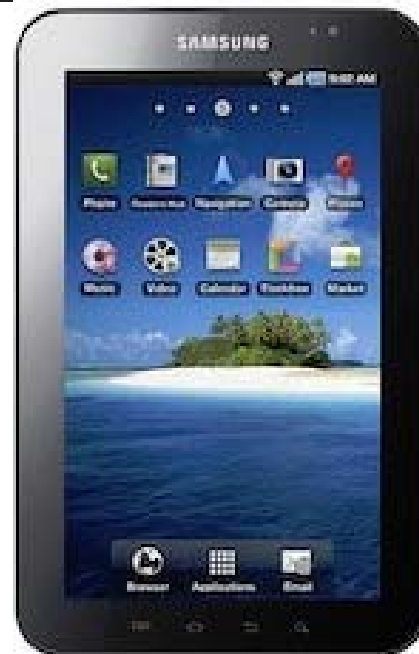
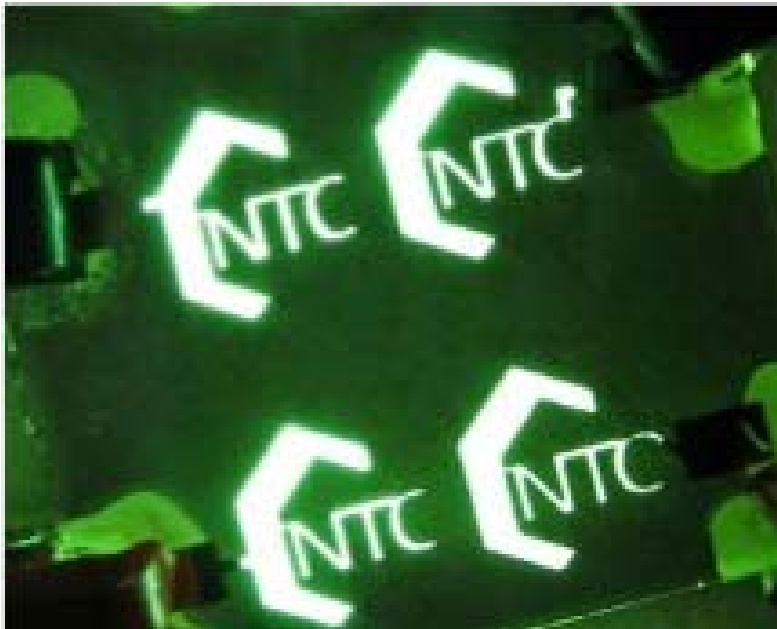
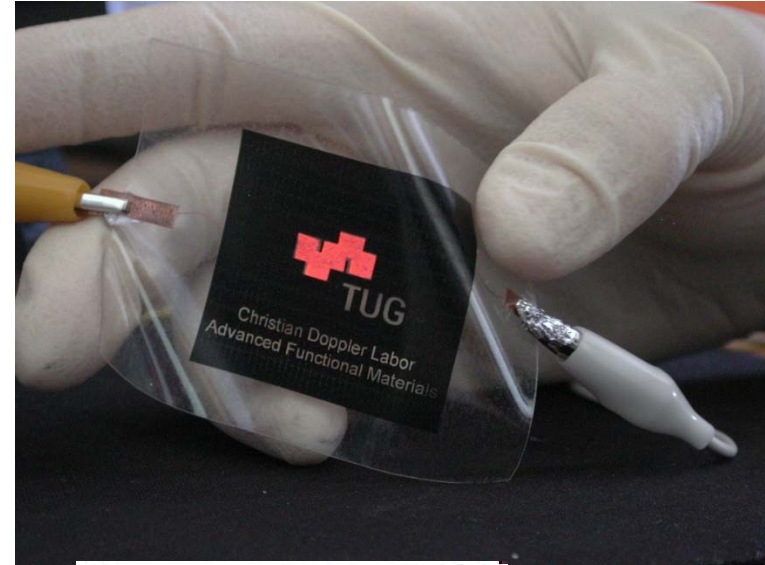
Light emitting diodes



absorption
reflection
total internal reflection



OLEDs



Galaxy Tab

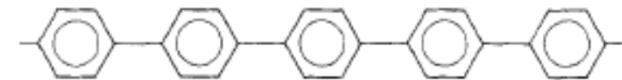
Encapsulation
technology

Electroluminescence in poly(p-phenylene)



Prof. Günther Leising

In 1992, Leising et al. for the first time reported on blue electroluminescence from OLEDs containing poly(p-phenylene) (PPP).

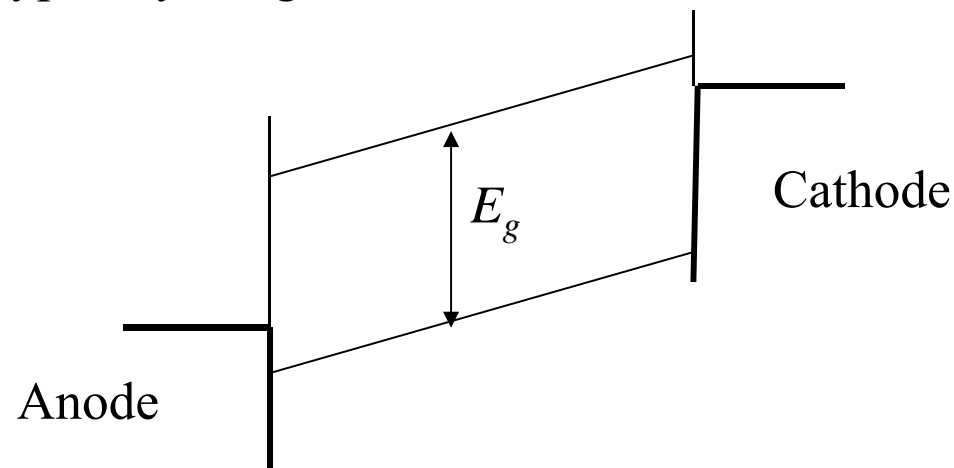


OLEDs

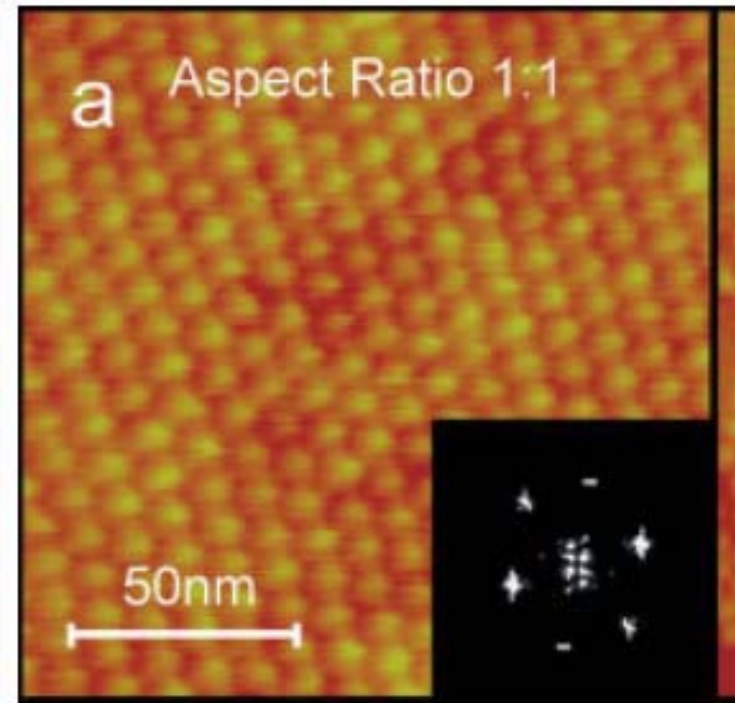
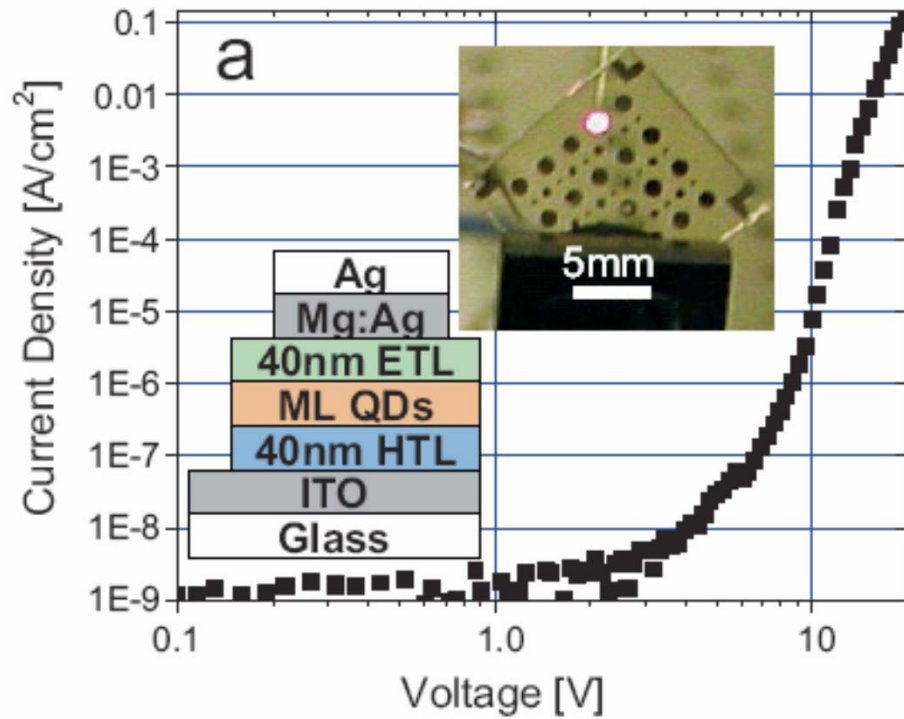
| |
|--------------------------|
| Aluminum cathode |
| Electron transport layer |
| Emission layer |
| Hole transport layer |
| ITO anode |
| Glass |

Cathode is typically a low work function material Al, Ca - injects electrons

Anode is typically a high work function material ITO - injects holes

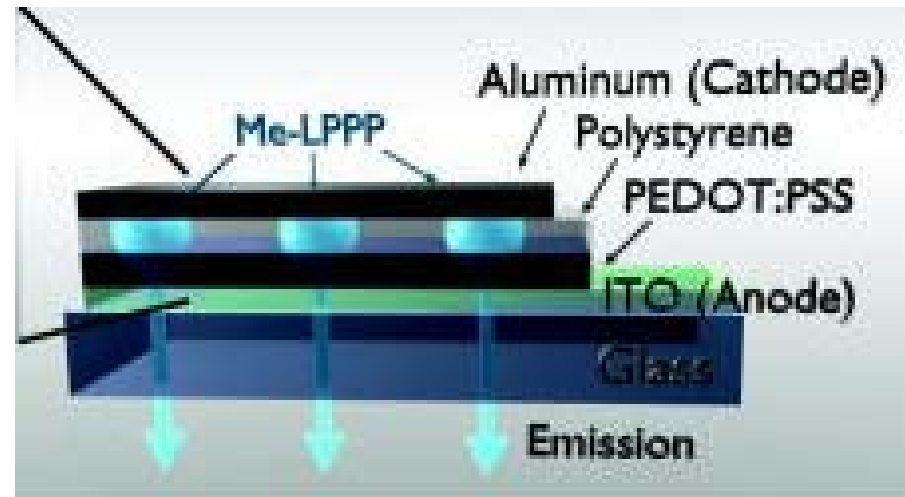
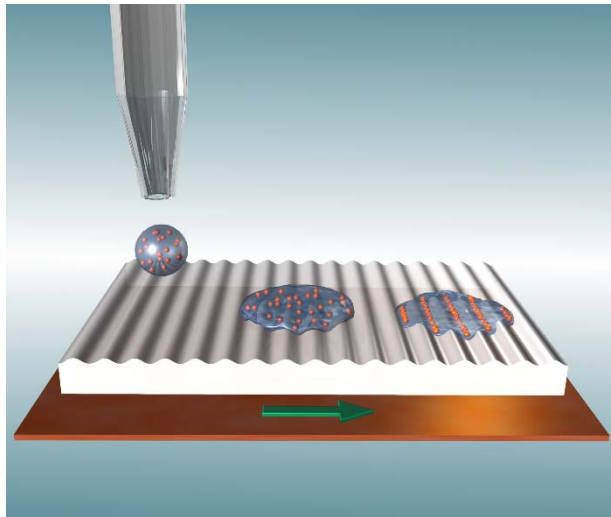


Q-dot LEDs



Coe-Sullivan, et al. *Advanced Functional Materials*,
10.1002/adfm.200400468

Nanoparticle OLEDs



Semiconductor nanosphere (Me-LPPP) OLEDs

Appl. Phys. Lett. 92, 183305 (2008)

Efficient lighting



Very efficient
Many colors possible
No toxic chemicals

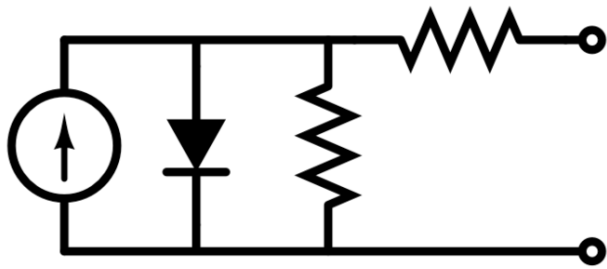
Flexible, transparent, wearable displays



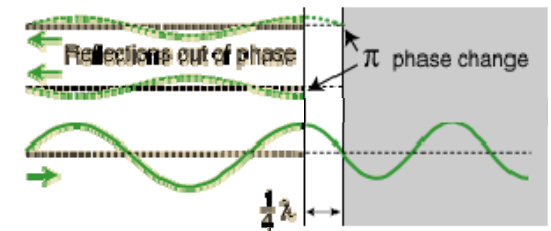
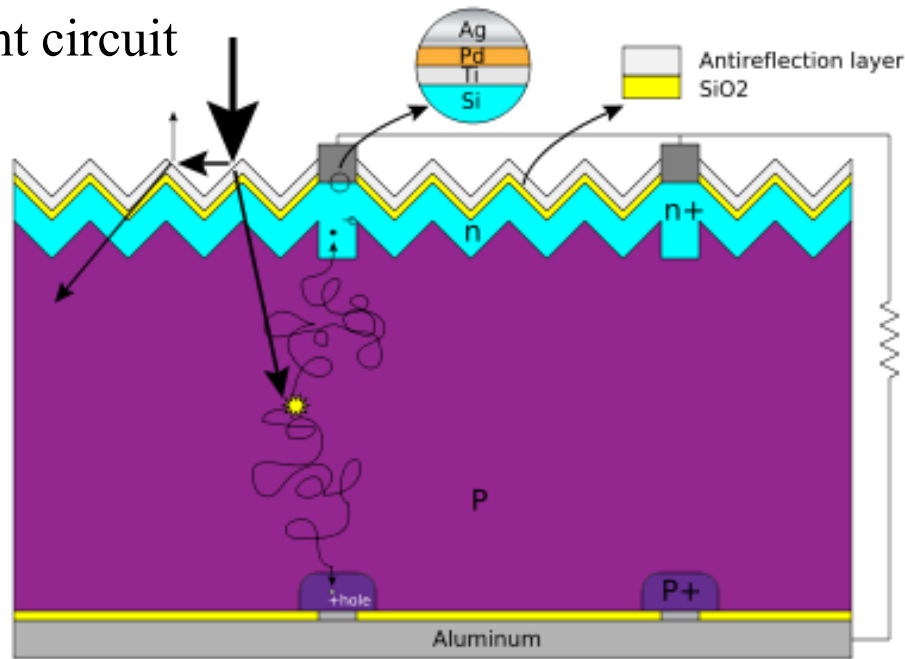
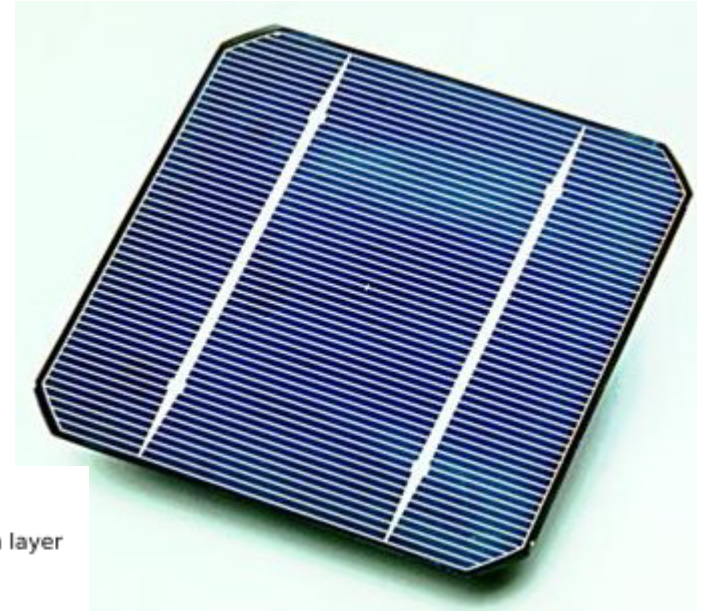
Transparent AMOLED

Folding display

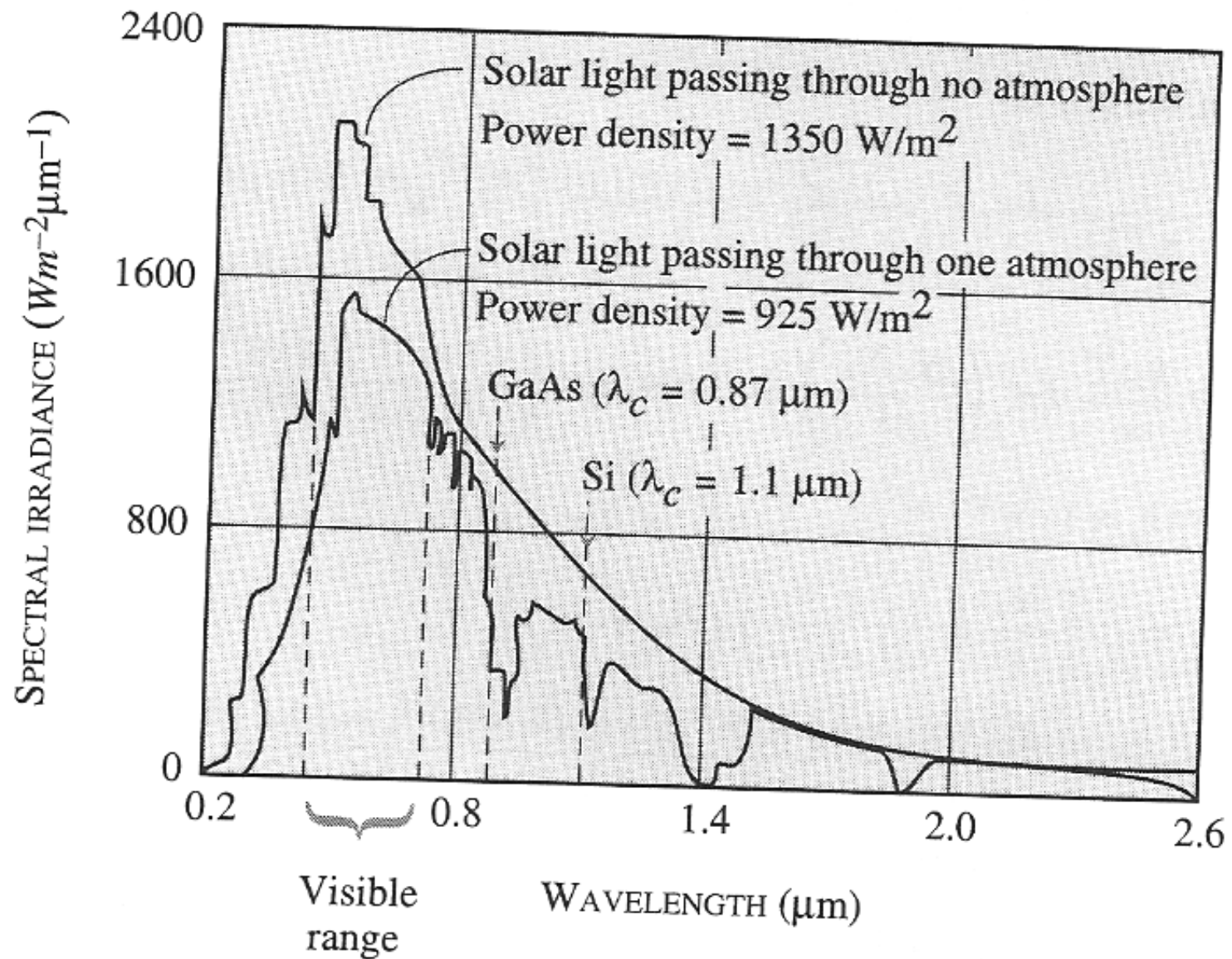
Solar cell



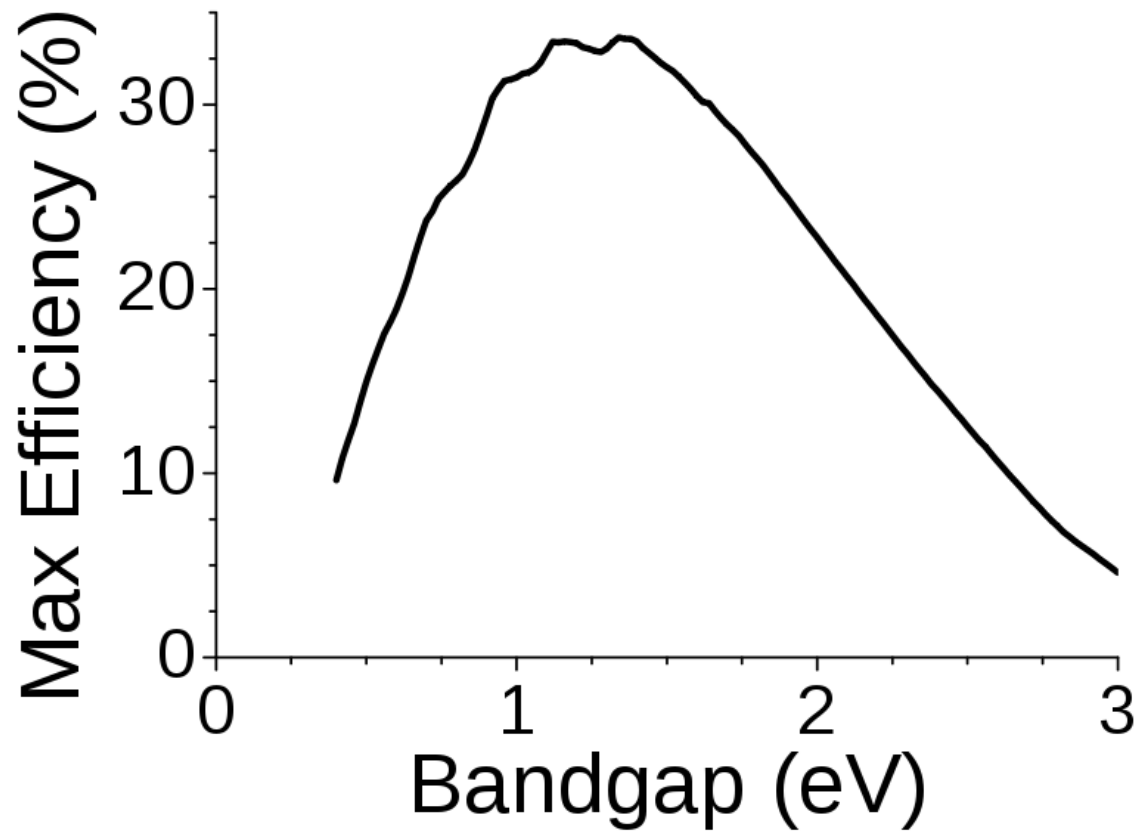
Equivalent circuit



Solar spectrum

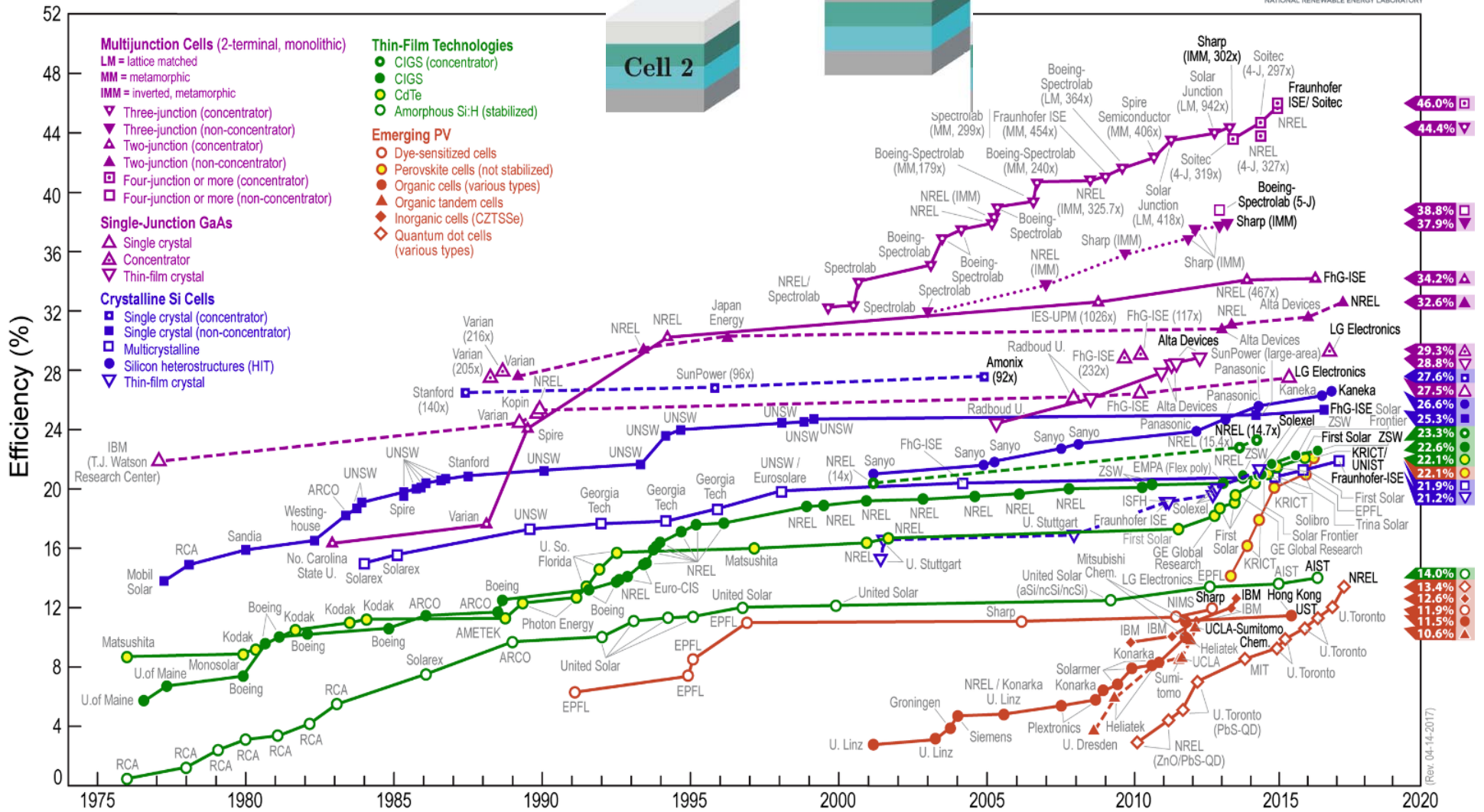
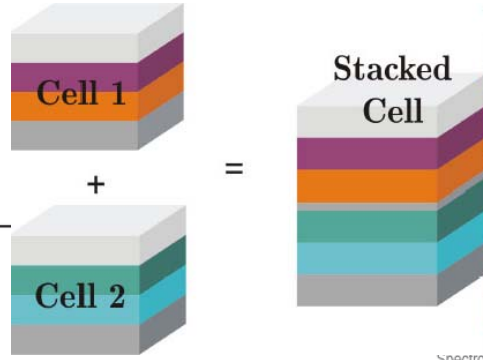


Shockley–Queisser limit



http://en.wikipedia.org/wiki/Shockley-Queisser_limit

Best Research-Cell Efficiencies



Biofuel efficiency ~ 1%

(Rev. 04-14-2017)